

IN THE U.S. PATENT AND TRADEMARK OFFICE

In re application of

Koichi NANIWAE

Conf. 9283

Application No. 10/573,492

Group 2892

Filed May 15, 2006

Examiner E. Jones

METHOD OF CLEANING TREATMENT AND METHOD FOR MANUFACTURING SEMICONDUCTOR DEVICE

AMENDMENT

Assistant Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450 December 23, 2008

Sir:

In response to the Non-final Office Action mailed August 27, 2008, please amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks begin on page 14 of this paper.